## Message Text

CONFIDENTIAL
PAGE 01 STATE 179888
71 ORIGIN EB-11
INFO OCT-01 CIAE-00 COME-00 DODE-00 NSAE-00 RSC-01 TRSE-00
EUR-25 AEC-11 EA-11 ISO-00 DRC-01 /061 R
DRAFTED BY EB/ITP/EWT:JMGREGORYJR. 9/10/73 EXT 20442 APPROVED BY EB/ITP/EWT:RBWRIGHT COMMERCE/OEC:KSEASWORD RPE
056449 P 110117Z SEP 73
FM SECSTATE WASHDC
TO USMISSION OECD PARIS PRIORITY
CONFIDENTIAL STATE 179888
EXCON
E.O. 11652: XGDS-1 TAGS: ESTC,COCOM, JA, PL SUBJECT: JAPANESE POLYCRYSTALLINE SILICON PLANT TO POLAND - IL 1355 REF: A. COCOM DOC(73) 1662 B. COCOM DOC(73) 933
NO OBJECTION TO REF A FOR SIMILAR REASONS TO THOSE PROFFERED REF B. RUSH
CONFIDENTIAL
NNN

## Message Attributes

Automatic Decaptioning: X Capture Date: 01 JAN 1994 Channel Indicators: n/a

**Current Classification: UNCLASSIFIED** Concepts: EXCEPTIONS LIST, SILICON

Control Number: n/a Copy: SINGLE Draft Date: 11 SEP 1973 Decaption Date: 01 JAN 1960 Decaption Note: Disposition Action: RELEASED Disposition Action: RELEASED
Disposition Approved on Date:
Disposition Authority: morefirh
Disposition Case Number: n/a
Disposition Comment: 25 YEAR REVIEW
Disposition Date: 28 MAY 2004
Disposition Event:
Disposition History: n/a
Disposition Reason:
Disposition Remarks:
Document Number: 1973STATE179888

Document Number: 1973STATE179888
Document Source: CORE
Document Unique ID: 00
Drafter: JMGREGORYJR.

Enclosure: n/a Executive Order: X1 WRIGHT

Errors: N/A Film Number: n/a From: STATE

Handling Restrictions: n/a

Image Path:

Legacy Key: link1973/newtext/t19730942/aaaabexn.tel Line Count: 43

Locator: TEXT ON-LINE Office: ORIGIN EB

Original Classification: CONFIDENTIAL Original Handling Restrictions: n/a Original Previous Classification: n/a

Original Previous Handling Restrictions: n/a

Page Count: 1

Previous Channel Indicators:
Previous Classification: CONFIDENTIAL Previous Handling Restrictions: n/a
Reference: A. COCOM DOC (73) 1662 Review Action: RELEASED, APPROVED Review Authority: morefirh

Review Comment: n/a Review Content Flags: Review Date: 23 AUG 2001

**Review Event:** 

Review Exemptions: n/a
Review History: RELEASED <23-Aug-2001 by shawdg>; APPROVED <19-Nov-2001 by morefirh>

**Review Markings:** 

Declassified/Released US Department of State EO Systematic Review 30 JUN 2005

**Review Media Identifier:** Review Referrals: n/a Review Release Date: n/a Review Release Event: n/a **Review Transfer Date:** Review Withdrawn Fields: n/a

Secure: OPEN Status: NATIVE

Subject: JAPANESE POLYCRYSTALLINE SILICON PLANT TO POLAND - IL 1355 TAGS: ESTC, JA, PL, COCOM To: OECD PARIS

Type: TE

Markings: Declassified/Released US Department of State EO Systematic Review 30 JUN 2005